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标题: Terahertz emission from Indium Oxide films grown on MgO substrates using sub-bandgap photon energy excitation

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摘要: Indium oxide (In<sub>2</sub>O<sub>3</sub>) films grown by thermal oxidation on MgO substrates were optically excited by femtosecond laser pulses having photon energy lower than the In<sub>2</sub>O<sub>3</sub> bandgap. Terahertz (THz) pulse emission was observed using time domain spectroscopy. Results show that THz emission saturates at an excitation fluence of similar to 400 nJ/cm<sup>2</sup>. Even as two-photon absorption has been excluded, the actual emission mechanism has yet to be confirmed but is currently attributed to carriers due to weak absorption from defect levels that are driven by a strain field at the interface of the substrate and the grown film. (C)2012 Optical Society of America

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